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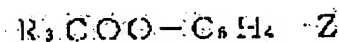
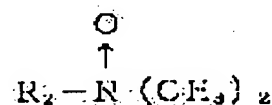
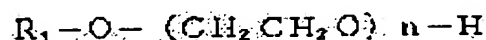
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NISHIOKA JIYUNO**(54) LIQUID BLEACHING AGENT COMPOSITION**

(57)Abstract:

**PROBLEM TO BE SOLVED:** To obtain a liquid bleaching agent composition excellent in preservation stability and expressing strong bleaching effects by effectively generating a peracid during cleaning by combining specific surfactants, hydrogen peroxide, a specific organic peracid precursor, water with an auxiliary solubilizing agent and a specific chelate.

**SOLUTION:** This liquid bleaching agent composition comprises (A) a surfactant (A1) of a compound, etc. expressed by formula I [R1 is an 8-18C (branched) alkyl or alkenyl; (n) is 2-30] and a surfactant (A2) of a compound, etc. expressed by formula II (R2 is R1), (B) hydrogen peroxide, (C) a compound of formula III [R3 is a 7-12C straight chain alkyl; Z is an alkali metal (M1) or a group expressed by the formula: COOM (M is H or M1), etc.], (D) water (D1) and an auxiliary solubilizing agent (D2) and (E) a phosphonic acid-based chelating agent. The composition comprises 5-30wt.% ingredient (A), 0.5-10wt.% (B), 0.1-10wt.% (C), 0-5wt.% (E) and rest wt.% of (D). The weight ratios of A1/B1 and D1/D2 are (1000/1)-(10/1) and (1/0)-(1/10), respectively and the pH of the solution is regulated to 2.5-4.5.

**LEGAL STATUS**

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